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March 22, 2006

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Fr: George O. Saile, Reg. No. 19,572 28 Davis Avenue Poughkeepsie, NY 12603

Subject:	ا	Serial No.	10/660,914	09/12/03
		Chao-Peng	Chen et al.	
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SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Enclosed is Form PTO-1449, Information Disclosure Citation In An Application.

The following Patents and/or Publications are submitted to comply with the duty of disclosure under CFR 1.97-1.99 and 37 CFR 1.56.

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on March 22, 2006.

Stephen B. Ackerman, Reg. # 37761

Signature/Date 3/22/08

HTIRC-02-013

Chemistry of a Chemically Amplified Negative Resist and Process Modification

for Electron Beam Exposure, by Shigeki Yamamoto et al., Presented by Patrick Martens,

Sumitomo Chemical America, discusses the chemistry of a chemically amplified negative

resist and process modification for electron beam exposure.

Perpendicular Recording Head Technology, DASCOM Business Group, TDK

Corporation, Japan, 07/23/02, p.5, discusses the ABS view of perpendicular head: Single

Pole.

The paper "Bake Condition Effect on Hybrid Lithography Process for Negative

Tone Chemically Amplified Resists," by L. Pain et al., Advances in Resist Technology

and Processing XVII, Francis M. Houlihan, Editor, Proceedings of SPIE, Vol. 3999

(2000), 0277-786X/00, presents the process optimization study of negative tone

Chemically Amplified Resists (CAR) under E-Beam exposure.

Sincerely,

Stephen B. Ackerman,

Reg. No. 37761

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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

EXAMINER